

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant	:	Takeshita et al.
Appl. No.	:	10/580,768
Filed	:	May 25, 2006
For	:	POSITIVE RESIST COMPOSITION AND METHOD FOR FORMING RESIST PATTERN
Examiner	:	Eoff, A.
Group Art Unit	:	1795

AMENDMENT AND RESPONSE TO RESTRICTION REQUIREMENT**Mail Stop Amendment**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

In response to the Restriction Requirement mailed **March 19, 2008**, please consider the following amendments and remarks.

Amendments to the claims are reflected in the listing of claims which begin on page 2 of this paper.

Remarks/Response to restriction requirement begin on page 9 of this paper.